

## UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of

Adrien Dromard et al.

Mail Stop AMENDMENT

Group Art Unit: 1793

Application No.: 10/583,417 Serena L. Hanor

Filed: April 26, 2007 Confirmation No.: 3689

For: HIGHLY-STRUCTURED SILICA

HAVING A LOW WATER UPTAKE,

PREPARATION METHOD
THEREOF AND USES OF THE

SAME

## AMENDMENT PURSUANT TO 37 C.F.R. §1.111

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

In response to the Office Action dated February 17, 2009, please amend the above-identified patent application as follows: